Integrated Circuit Design

Iain McNally

 $\approx 12 \ lectures$

Koushik Maharatna

 $\approx 12 \ lectures$

1001

Integrated Circuit Design

Iain McNally

Content

- Introduction
- Overview of Technologies
- Layout
- Design Rules and Abstraction
- Cell Design and Euler Paths
- System Design using Standard Cells
- Pass Transistor Circuits
- Storage
- PLAs
- Wider View

Assessment 0% Informal Coursework (L-Edit Gate Layout) 100% Examination Books Digital Integrated Circuits Jan Rabaey Prentice-Hall Principles of CMOS VLSI Design A Circuits and Systems Perspective Neil Weste & David Harris Addison-Wesley 2004 Notes & Resources

http://users.ecs.soton.ac.uk/bim/notes/icd

1003

History

1947 First Transistor John Bardeen, Walter Brattain, and William Shockley (Bell Labs)	
1952 Integrated Circuits Proposed Geoffrey Dummer (Royal Radar Establishment) - <i>prototype failed</i>	
1958 First Integrated Circuit Jack Kilby (Texas Instruments) - Co-inventor	
1959 First Planar Integrated Circuit Robert Noyce (Fairchild) - <i>Co-inventor</i>	
1961 First Commercial ICs Simple logic functions from TI and Fairchild	
1965 Moore's Law Gordon Moore (Fairchild) observes the trends in integration.	

History

Moore's Law

Predicts exponential growth in the number of components per chip.

1965 - 1975 Doubling Every Year

In 1965 Gordon Moore observed that the number of components per chip had doubled every year since 1959 and predicted that the trend would continue through to 1975.

Moore describes his initial growth predictions as "ridiculously precise".

1975 - 2010 Doubling Every Two Years

In 1975 Moore revised growth predictions to doubling every two years.

Growth would now depend only on process improvements rather than on more efficient packing of components.

In 2000 he predicted that the growth would continue at the same rate for another 10-15 years before slowing due to physical limits.

1005

History

Moore's Law; a Self-fulfilling Prophesy

The whole industry uses the Moore's Law curve to plan new fabrication facilities.

Slower - wasted investment

Must keep up with the Joneses².

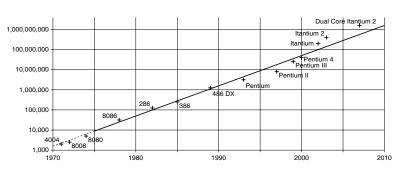
Faster - too costly

Cost of capital equipment to build ICs doubles approximately every 4 years.

²or the Intels

1007

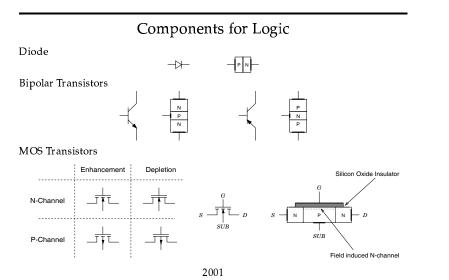
History



Moore's Law at Intel¹

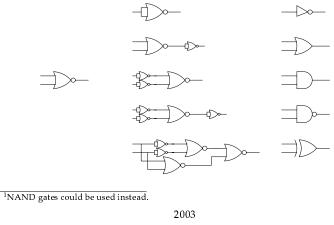
¹Intel was founded by Gordon Moore and Robert Noyce from Fairchild

Overview of Technologies



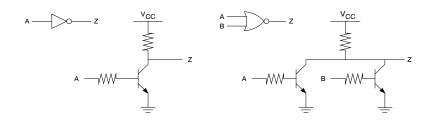
Overview of Technologies

All functions can be realized with a single NOR base gate.¹

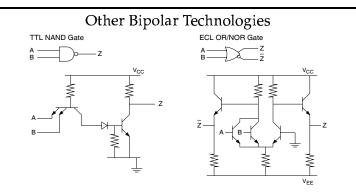


Overview of Technologies

RTL Inverter and NOR gate



Overview of Technologies

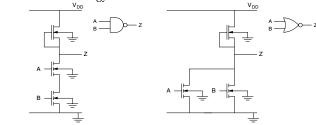


- TTL gives faster switching than RTL at the expense of greater complexity². The characteristic multi-emitter transistor reduces the overall component count.
- ECL is a very high speed, high power, non-saturating technology.

²Most TTL families are more complex than the basic version shown here

Overview of Technologies

NMOS - a VLSI technology.



- Circuit function determined by series/parallel combination of devices.
- Depletion transistor acts as non-linear load resistor.

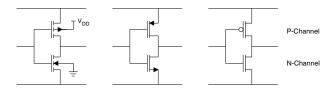
Resistance increases as the enhancement device turns on, thus reducing power consumption.

• The low output voltage is determined by the size ratio of the devices.

2005

Digital CMOS Circuits

Alternative representations for CMOS transistors

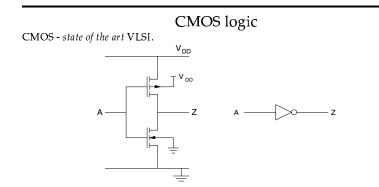


Various shorthands are used for simplifying CMOS circuit diagrams.

- In general substrate connections are not drawn where they connect to Vdd (PMOS) and Gnd (NMOS).
- All CMOS devices are enhancement mode.
- Transistors act as simple digitally controlled switches.

2007

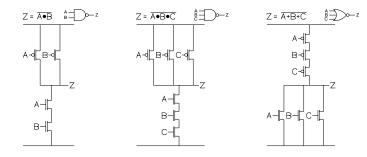
Overview of Technologies



- An active PMOS device complements the NMOS device giving:
 - rail to rail output swing.
 - negligible static power consumption.

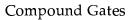
Digital CMOS Circuits

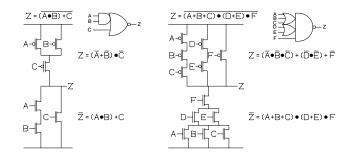
Static CMOS complementary gates



• For any set of inputs there will exist either a path to Vdd or a path to Gnd.

Digital CMOS Circuits



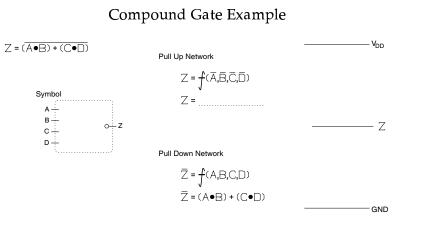


• All compound gates are inverting.

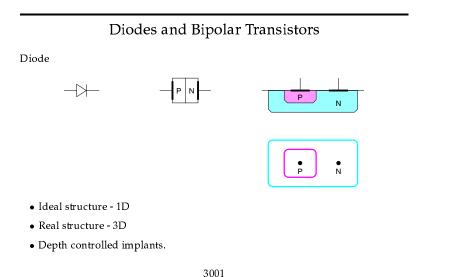
• Realisable functions are arbitrary AND/OR expressions with inverted output.

2009

Digital CMOS Circuits



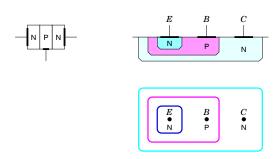
Components for Digital IC Design



Components for Digital IC Design

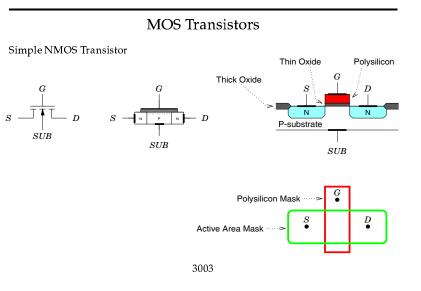
Diodes and Bipolar Transistors

NPN Transistor



• Two n-type implants.

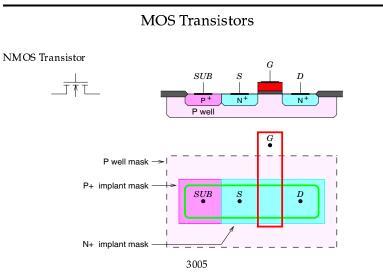
Components for Digital IC Design



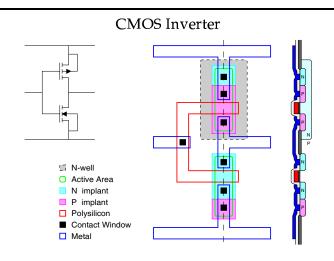
Components for Digital IC Design

Simple NMOS Transistor

- Active Area mask defines extent of Thick Oxide.
- Polysilicon mask also controls extent of *Thin Oxide* (alias *Gate Oxide*).
- N-type implant has no extra mask.
- It is blocked by thick oxide and by polysilicon.
- The implant is Self Aligned.
- Substrate connection is to bottom of wafer.
- All substrates to ground.
- Gate connection not above transistor area.
- Design Rule.



CMOS Process



3007

Components for Digital IC Design

NMOS Transistor

Where it is not suitable for substrate connections to be shared, a more complex process is used.

- Five masks must be used to define the transistor:
 - P Well
 - Active Area
 - Polysilicon
 - N+ implant
 - P+ implant
- P Well, for isolation.
- Top *substrate* connection.
- P+/N+ implants produce good *ohmic* contacts.

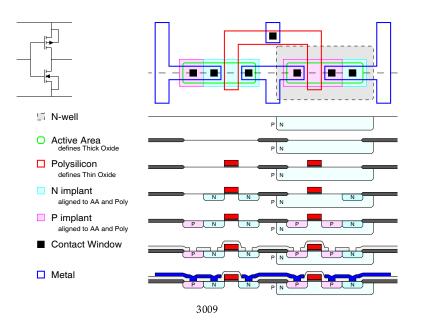
CMOS Process

CMOS Inverter

- The process described here is an *N Well process* since it has only an N Well. P Well and Twin Tub processes also exist.
- Note that the P-N junction between chip substrate and N Well will remain reverse biased.

Thus the transistors remain isolated.

- N implant defines NMOS source/drain and PMOS substrate contact.
- P implant defines PMOS source/drain and NMOS substrate contact.

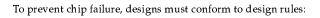


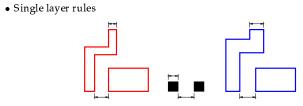
Photolithography

Contact/Proximity Mask	Glass Mask Mask Pattern (chrome)	Photoresist Exposure
Silicon Wafer	7	Photoresist Development
Oxide Growth		Oxide Etch
	SiO 2	
Photoresist Deposition	Photoresist (positive)	Photoresist Strip

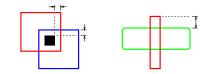
4001

Design Rules



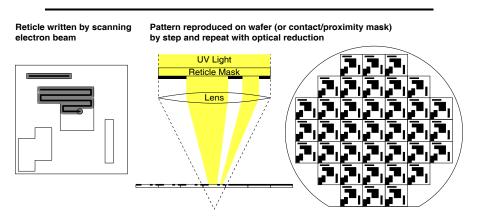


• Multi-layer rules



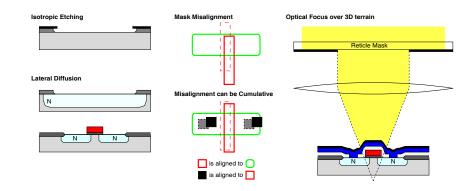
4003

Mask Making

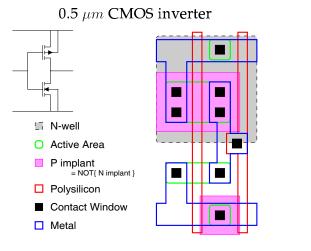


• Optical reduction allows narrower line widths.

Derivation of Design Rules

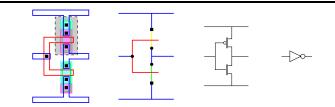


Design Rules



4005

Abstraction - Stick Diagrams



Stick diagrams give us many of the benefits of abstraction:

- Much easier / faster than full mask specification.
- Process independent (valid for any CMOS process).
- Easy to change.

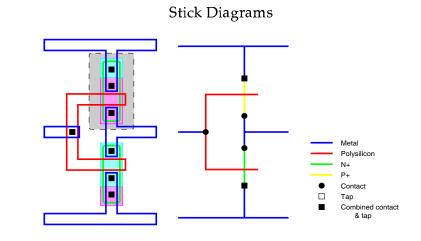
while avoiding some of the problems:

• Optimized layout may be generated much more easily from a stick diagram than from transistor or gate level designs.¹

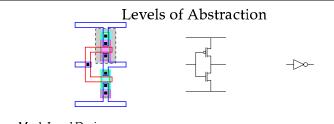
¹note that all IC designs must end at the mask level.

4007

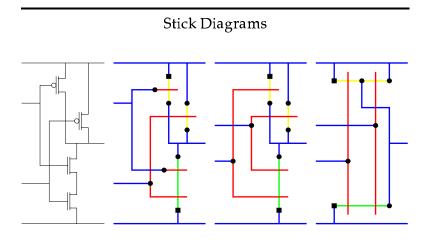
Digital CMOS Design



Abstraction



- Mask Level Design
- Laborious Technology/Process dependent.
- Design rules may change during a design!
- Transistor Level Design
- Process independent, Technology dependent.
- Gate Level Design
- Process/Technology independent.



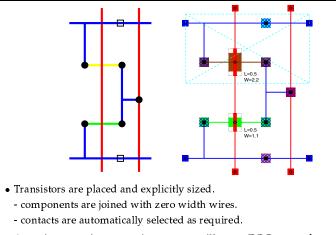
4009

Digital CMOS Design

Stick Diagrams

- Explore your Design Space.
 - Implications of crossovers.
 - Number of contacts.
 - Arrangement of devices and connections.
- Process independent layout.
- Easy to expand to a full layout for a particular process.

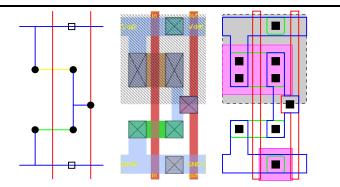
Sticks and CAD - Symbolic Capture



• A semi-automatic compaction process will create DRC correct layout.

4011

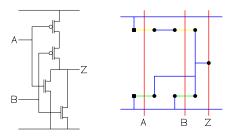
Sticks and CAD - Magic



- Log style design (sticks with width) DRC errors are flagged immediately. - again contacts are automatically selected as required.
- On-line DRC leads to rapid generation of correct designs.
- symbolic capture style compaction is available if desired.

A logical approach to gate layout.

• All complementary gates may be designed using a single row of n-transistors above or below a single row of p-transistors, aligned at common gate connections.

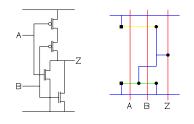


5001

Digital CMOS Design

Euler Path

- For the majority of these gates we can find an arrangement of transistors such that we can butt adjoining transistors.
 - Careful selection of transistor ordering.
 - Careful orientation of transistor source and drain.
- Referred to as line of diffusion.



Digital CMOS Design

Finding an Euler Path

Computer Algorithms

• It is relatively easy for a computer to consider all possible arrangements of transistors in search of a suitable Euler path.

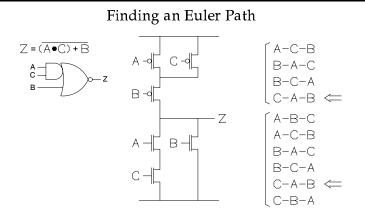
This is not so easy for the human designer.

One Human Algorithm

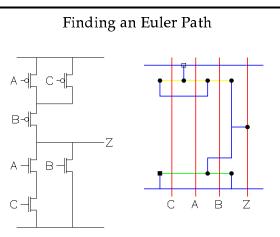
- Find a path which passes through all n-transistors exactly once.
- Express the path in terms of the gate connections.
- Is it possible to follow a similarly labelled path through the p-transistors?
 - Yes you've succeeded.
 - No try again (you may like to try a p path first this time).

5003

Digital CMOS Design

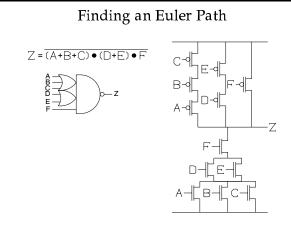


Here there are four possible Euler paths.



5005

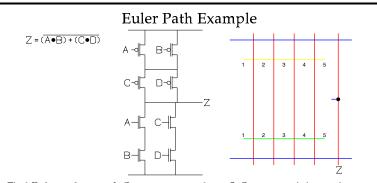
Digital CMOS Design



No possible path through n-transistors!

5007

Digital CMOS Design

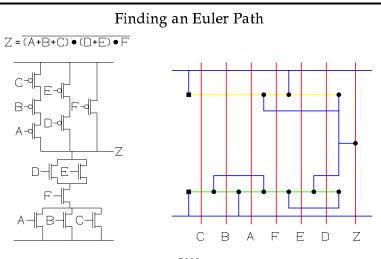


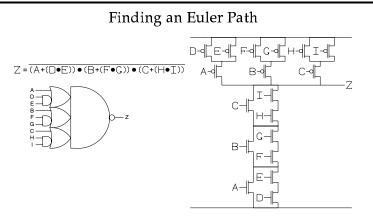
1. Find Euler path 3. Route power nodes 5. Route remaining nodes 2. Label poly columns 4. Route output node 6. Add taps¹ for PMOS and NMOS A combined contact and tap, \blacksquare , may be used only where a power contact exists at the end of a line of diffusion. Where this is not the case a simple tap, 🖶 , should be used.

¹1 tap is good for about 6 transistors – insufficient taps may leave a chip vulnerable to latch-up

Digital CMOS Design

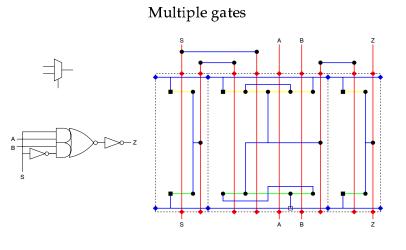
B





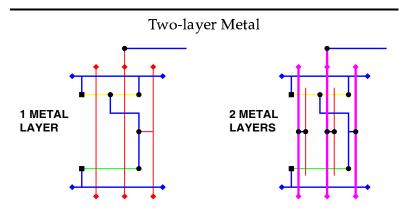
No possible path through p-transistors. No re-arrangement will create a solution!





6001

Digital CMOS Design



Most modern VLSI processes support two or more metal layers. The norm is to use only metal for inter-cell routing. Usually Metal1 horizontally (and for power rails) and Metal2 vertically (and for cell inputs and outputs).

6003

Digital CMOS Design

Multiple gates

- Gates should all be of same height.
 - Power and ground rails will then line up when butted.
- All gate inputs and outputs are available at top and bottom.
 - All routing is external to cells.
 - Preserves the benefits of hierarchy.
- Interconnect is via two conductor routing.
 - In this case Polysilicon vertically and Metal horizontally.

Standard Cell Design

Many ICs are designed using the standard cell method.

• Cell Library Creation

A cell library, containing commonly used logic gates, is created for a process. This is often carried out by or on behalf of the foundry.

• ASIC¹ Design

The ASIC designer must design a circuit using the logic gates available in the library.

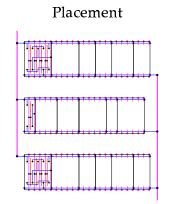
The ASIC designer usually has no access to the full layout of the standard cells and doesn't create any new cells for the library.

Layout work performed by the ASIC designer is divided into two stages:

- Placement
- Routing

¹Application Specific Integrated Circuit

Placement & Routing

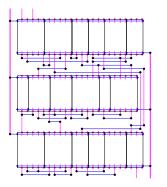


Cells are placed in one or several equal length lines with inter-digitated power and ground rails.

6005

Placement & Routing





In the routing channels between the cells we route metall horizontally and metal2 vertically.

Placement & Routing

Two conductor routing

• This logical approach means that we should never have to worry about signals crossing.

This makes life considerably easier for a computer (or even a human) to complete the routing.

- We must only ensure that two signals will not meet in the same horizontal or vertical channel.
- \bullet Computer algorithms can be used to ensure placement of cells such that wires are short.^2
- Further computer algorithms can be used to optimize the routing itself.

 $^2 \mathrm{In}$ VLSI circuits we often find that inter-cell wiring occupies more area than the cells themselves.

6007

Standard Cell Design

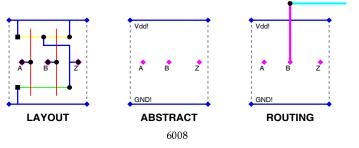
More Metal Layers

With three or more metal layers it is possible to take a different approach. The simplest example uses three metal layers.

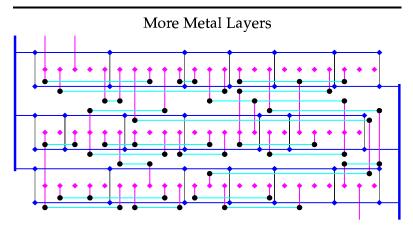
Standard Cells

Use only metal1 except for I/O which is in metal2

• Two Conductor Routing Uses metal2 and metal3



Standard Cell Design

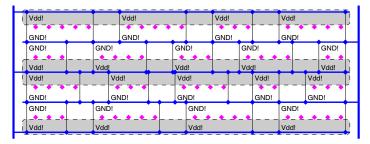


With this approach we can route safely over the cell to the specified pins leading to much smaller gaps between cell rows.

6009

Standard Cell Design

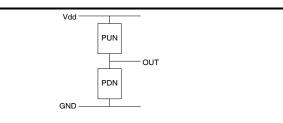
Alternative Placement Style



By flipping every second row it may be possible to eliminate gaps between rows. N-wells are merged and power or ground rails are shared.

This approach is normally associated with sparse rows and non channel based routing algorithms.

Static CMOS Complementary Gates



• Static

After the appropriate propagation delay the ouput becomes valid and remains valid. $^{\rm 1}$

• Complementary

For any set of inputs there will exist either a path to Vdd or a path to GND.

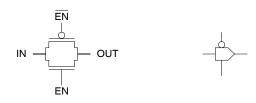
Where this condition is not met we have either a high impedence output or a conflict in which the strongest path succeeds. Static CMOS **Non-complementary** gates make use of these possibilities.

¹c.f. Dynamic logic which uses circuit capicitance to store state for a short time.

7001

Pass Transistor Circuits

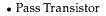
- Transmission Gate
 - For static circuits we would normally use a CMOS transmission gates:



- balanced *n* and *p* pass transistors- faster pull-up
- -- slower pull-down

7003

Pass Transistor Circuits

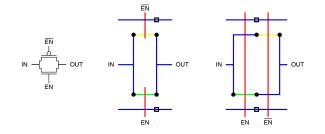


- Provides very compact circuits.
- Good transmission of logic '0'.
- Poor transmission of logic '1'.
- - slow rise time
- - degradation of logic value

The pass transistor is used in many dynamic CMOS circuits².

Pass Transistor Circuits

• Transmission Gate Layout



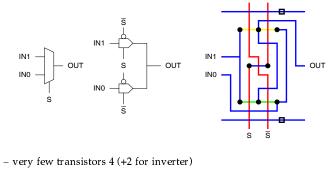
note that these circuits are not fully complementary³ hence they do not immediately lend themselves to a *line of diffusion* implementation.

³since there are sets of inputs for which the output is neither pulled low nor high

²where pull-up is performed by an alternative method

Pass Transistor Circuits

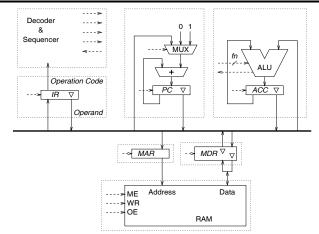
• Transmission Gate Multiplexor



- difficult layout may offset this advantage
- - prime candidate for 2 level metal

7005

Bus Distributed Multiplexing

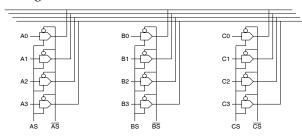


Ideal for signals with many drivers from different modules.

7007

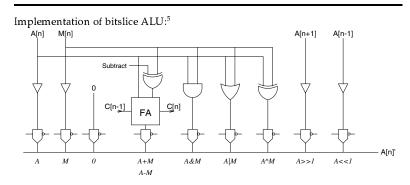
Pass Transistor Circuits

• Bus Wiring



- distributed multiplexing⁴
- only one inverter required per bank of transmission gates
- greatly simplifies global wiring

Bus Distributed Multiplexing

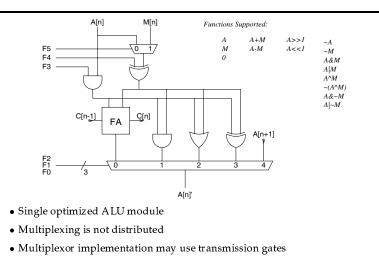


- Separate circuit for each function
- Connected via distributed multiplexor

⁴internal chip bus should never be allowed to float high impedance

⁵Note that transmission gates have no drive capability in themselves. Here a good drive is ensured by providing buffers.

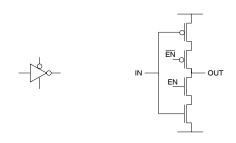
Bus Distributed Multiplexing



7009

Pass Transistor Circuits

• Tristate Inverter



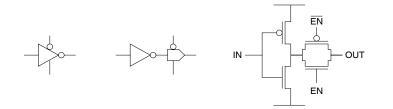
- Alternatively the transmission gate may be incorporated into the gate.
- -- one connection is removed easier to layout

- - also easier to simulate!

7011

Pass Transistor Circuits

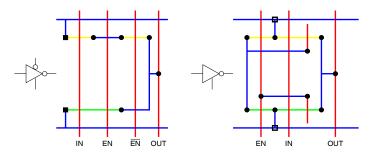
• Tristate Inverter



- Any gate may have a tri-state output by combining it with a transmission gate.

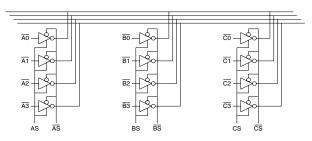
Pass Transistor Circuits

• Tristate Inverter Layout



Pass Transistor Circuits

• Tristate Inverter Bus Driver

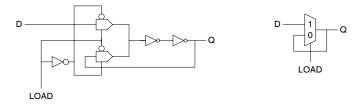


- a tristate inverting buffer is often used to drive high capacitance bus signals
- transistors may be sized as required



Latches and Flip-Flops

• CMOS transmission gate latch



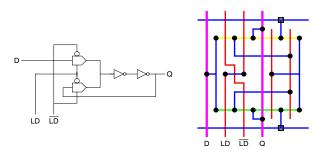
A simple transparent latch can be build around a transmission gate multiplexor

- transparent when load is high
- latched when load is low
- two inverters are required since the transmission gate cannot drive itself

8001

Latches and Flip-Flops

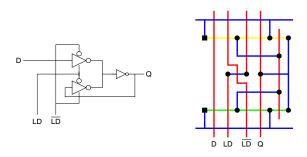
• Transmission gate latch layout



- a compact layout is possible using 2 layer metal

Latches and Flip-Flops

• A simpler layout may be achieved using tristate inverters.

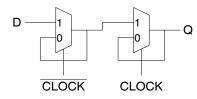


 this design requires two additional transistors but may well be more compact.

8003

Latches and Flip-Flops

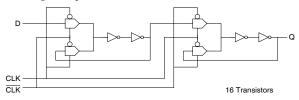
• For use in simple synchronous circuits we use a pair of latches in a master slave configuration.



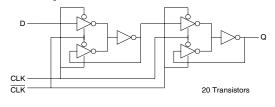
- this avoids the race condition in which a transparent latch drives a second transparent latch operating on the same clock phase.
- the circuit behaves as a rising edge triggered D type flip-flop.

Latches and Flip-Flops

• Transmission gate implementation



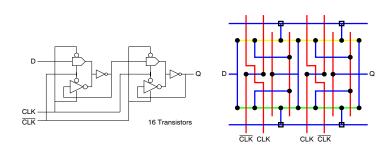
• Tristate inverter implementation



8005

Latches and Flip-Flops

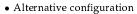
• Layout of master slave D type.

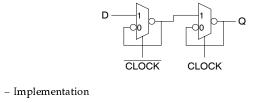


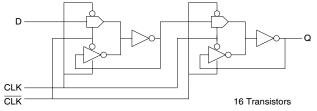
- very compact using alternative configuration.

8007

Latches and Flip-Flops







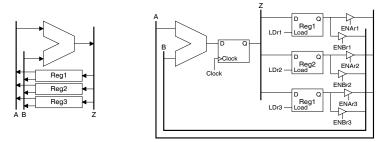
Latches and Flip-Flops

- For the same functionality we could use an edge triggered D type: CLF CLK 26 Transistors - a few more transistors

 - more complex wiring
 - simpler clock distribution

Register File

Where we have large amounts of storage the use of individual latches can lead to space saving.



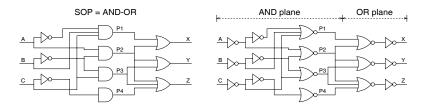
• Load signals must be glitch free with tightly controlled timing.

• Edge Triggered D-type prevents a race condition ($Reg1 \leftarrow Reg1 + Reg2$).



PLA structures

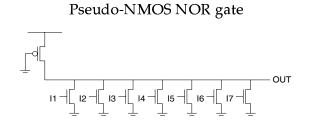
Programmable Logic Array structures provide a logical and compact method of implementing multiple SOP (Sum of Products) or POS expressions.



Most PLA structures employ pseudo-NMOS NOR gates using a P-channel device in place of the NMOS depletion load.

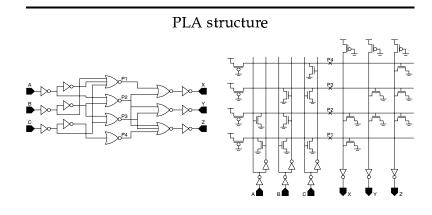
9001

PLAs, ROMs and RAMs



- Unlike complementary CMOS circuits, these gates will dissipate power under static conditions (since the P device is always on).
- The P and N channel devices must be ratioed in order to create the required low output voltage.
- This ratioing results in a slower gate, although there is a trade-off between gate speed and static power dissipation.

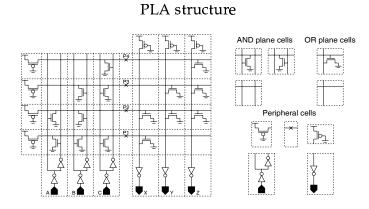
PLAs, ROMs and RAMs



• A regular layout is employed, with columns for inputs and outputs and rows for intermediate expressions.

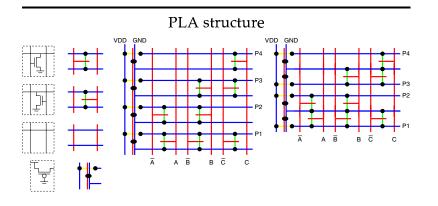
9003

PLAs, ROMs and RAMs



• Layout is simply a matter of selecting and placing rectangular cells from a limited set.

PLAs, ROMs and RAMs



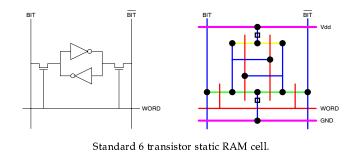
• Conversion to *sticks* is straight forward with opportunities for further optimization.

9005

PLAs, ROMs and RAMs

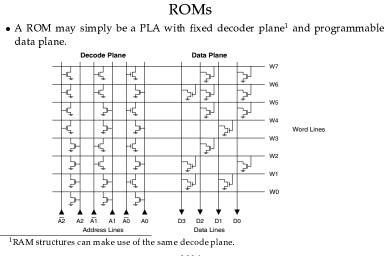
Static RAM

- Used for high density storage on a standard CMOS process.
- Short lived conflict during write NMOS transistors offer stronger path.
- Differential amplifiers are used for speedy read.

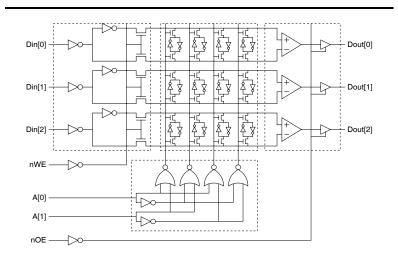


9007

PLAs, ROMs and RAMs



SRAM Structure

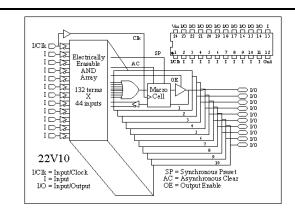


System Design Choices

- Programmable Logic
 - PLD
 - e.g. PAL 22V10, ICT PEEL22CV10, Lattice ispGAL22V10
 - Field Programmable Gate Array (FPGA)
 - e.g. Xilinx XC4013, Altera Cyclone EP1C12
- Semi-Custom Design
 - Mask Programmable Gate Array
 - e.g. ECS CMOS Gate Array
 - Altera HardCopy II structured ASICs
 - Standard Cell Design
 - e.g. Alcatel Mietec MTC45000 $0.35 \mu m$ cell library
- Full Custom Design

10001

Programmable Logic



- One time use Fuse programmable.
- Reprogrammable UV/Electrically Erasable.

10003

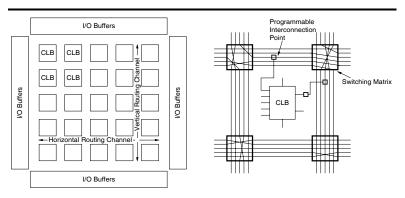
System Design Choices

• Programmable Logic

START HERE

- Best possible design turnaround time
- Cheapest for prototyping
- Best time to market
- Minimum skill required
- Semi-Custom Design
- Full Custom Design
 - Cheapest for mass production
 - Fastest
 - Lowest Power
 - Highest Density 1
 - Most skill required

Field Programmable Gate Array – Xilinx XC4000

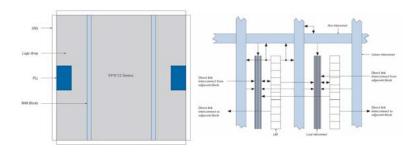


- Configurable Logic Blocks & I/O Blocks²
- Programmable Interconnect

 2 Xilinx XC4013 has 576 (24 \times 24) CLBs and up to 192 (4 \times 48) user I/O pins.

¹optimization limited by speed/power/area trade off

Field Programmable Gate Array – Altera Cyclone

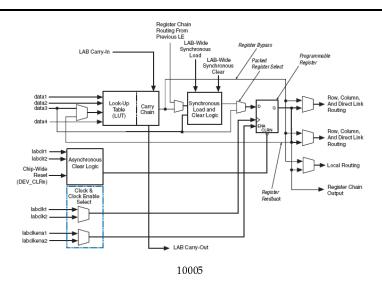


- Logic Array Blocks, M4K Ram Blocks & I/O Elements³
- Programmable Interconnect

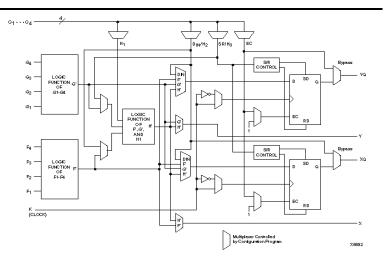
 $^{-3}$ Altera Cyclone EP1C12 has 12060 Logic Elements (arranged as 1206 Logic Array Blocks) and and up to 249 user I/O pins.

10004

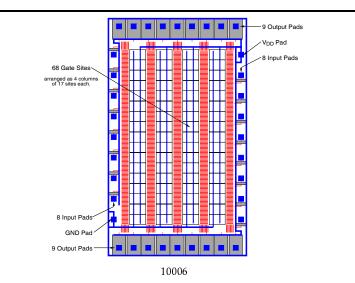
Field Programmable Gate Array – Altera Cyclone LE



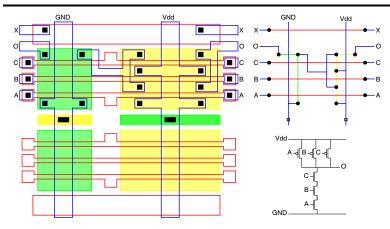
Field Programmable Gate Array - Xilinx XC4000 CLB



Mask Programmable Gate Array



Mask Programmable Gate Array

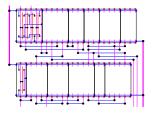


• Customize Metal and Contact Window masks only.

10007

Standard Cell Design

• Logic Functions



- Auto Generated Macro Blocks
 - PLA
 - ROM
 - RAM
- System Level Blocks

– Microprocessor $core^4$

⁴Will support System On Chip applications.

10008

Full Custom

All design styles need full custom designers

- to design the base programmable logic chips
- to design building blocks for semi-custom

Where large ASICs use full custom techniques they are likely to be used alongside semi-custom techniques.

e.g. Hand-held computer game chip

- Full custom bitslice datapath
- hand crafted for optimum area efficiency and low power consumption
- Standard cell controller
- Macro block RAM, ROM

10009